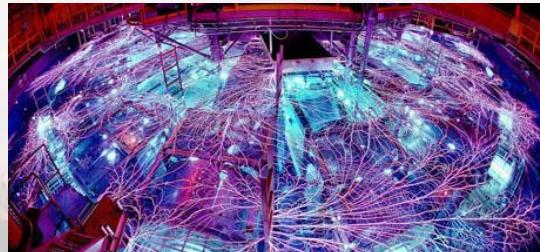


Measurement of dynamic strength at high pressures using magnetically applied pressure-shear (MAPS) on the Sandia Z accelerator

C.S. Alexander, T.A. Haill, D.G. Dalton, D.C. Rovang, D.C. Lamppa

Sandia National Laboratories

**APS-SCCM / AIRAPT Meeting
Seattle, Washington
July 7-12 2013**



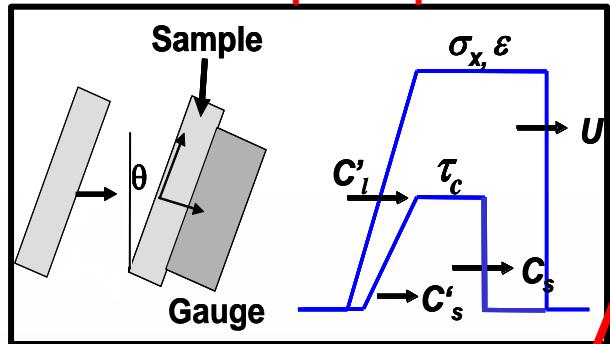
Sandia National Laboratories is a multi-program laboratory operated by Sandia Corporation, a wholly owned subsidiary of Lockheed Martin company, for the U.S. Department of Energy's National Nuclear Security Administration under contract DE-AC04-94AL85000.



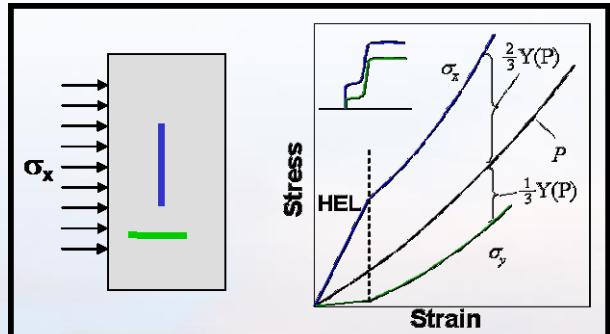
Sandia National Laboratories

Existing strength measurement techniques have limitations at high pressure

Oblique impact



Lateral gauges



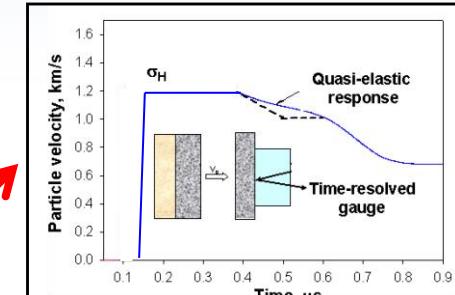
Limited to low P
(<200 kbar or 20 GPa)

Requires assumptions

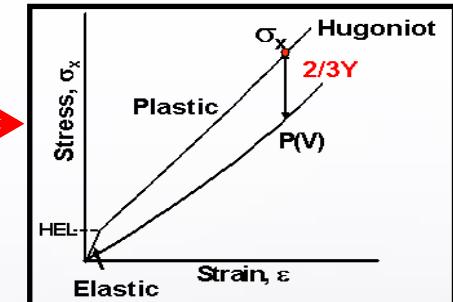
Large uncertainties

Requires accurate models
which are unknown

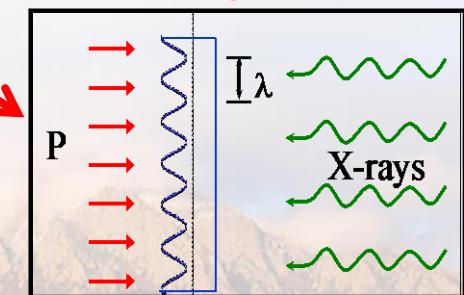
Wave Profile



Stress Difference



Rayleigh-Taylor

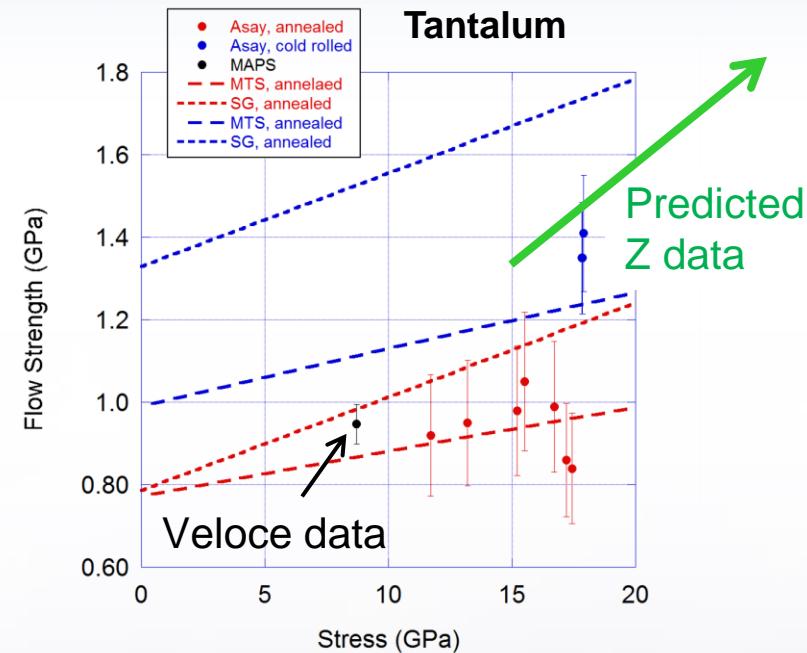
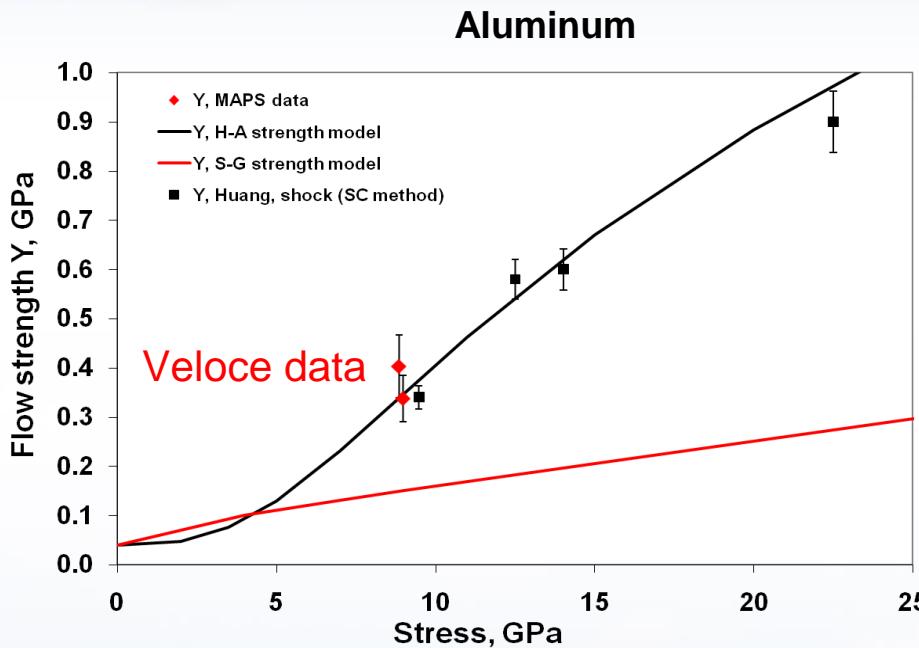


There is a need for improved strength measurement capability at high pressures



Sandia National Laboratories

MAPS directly measures strength at high pressures



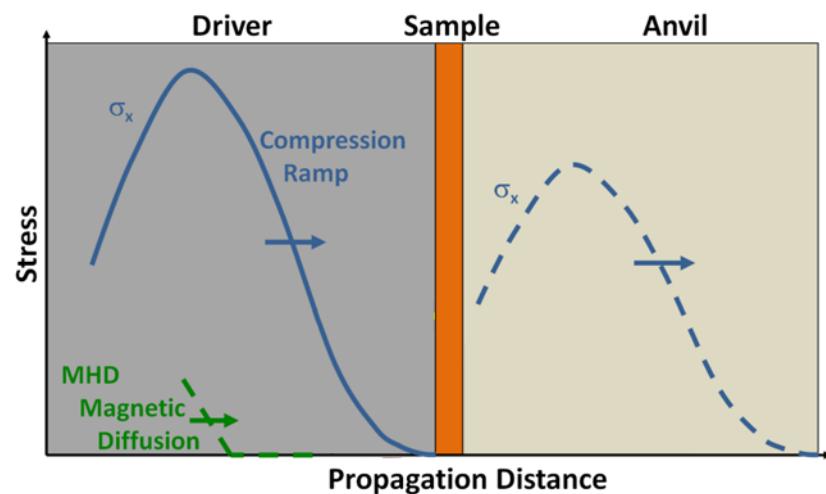
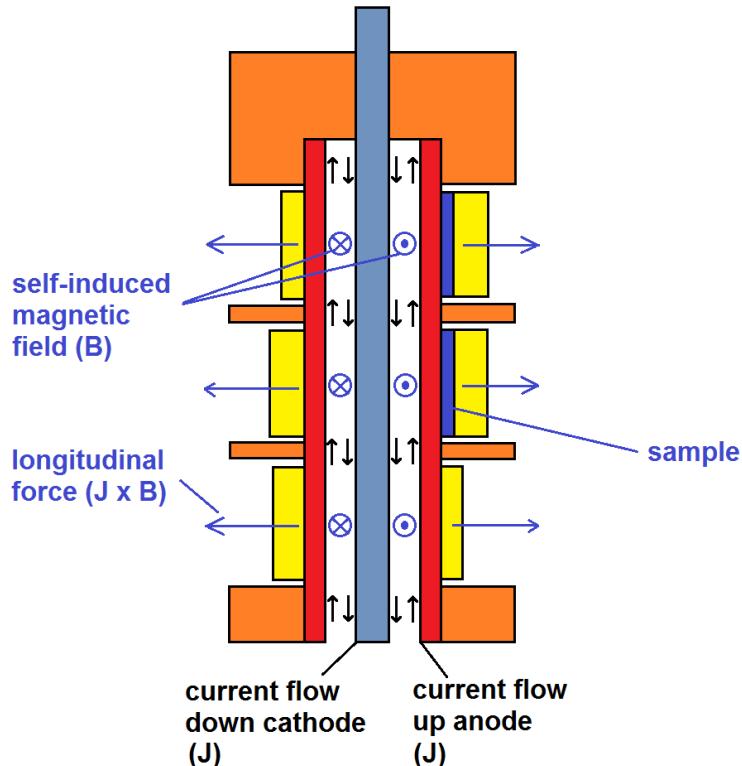
- Technique easily discriminates between strength models
- Z experiments are planned on Ta at 30 GPa and 50 GPa

1. C.S. Alexander, J. R. Asay and T. A. Haill, *J. Appl. Phys.* **108**, 126101 (2010)
2. H. Huang and J.R. Asay, *J. Appl. Phys.* **98**, 033524 (2005)
3. D.J. Steinberg, S.G. Cochran, and M.W. Guinan, *J. Appl. Phys.* **51**, 1498 (1980)
4. J.R. Asay et al., *J. Appl. Phys.* **106**, 073515 (2009)



Sandia National Laboratories

Pulsed power drives generate pressure ramps with electric current flowing on parallel plates

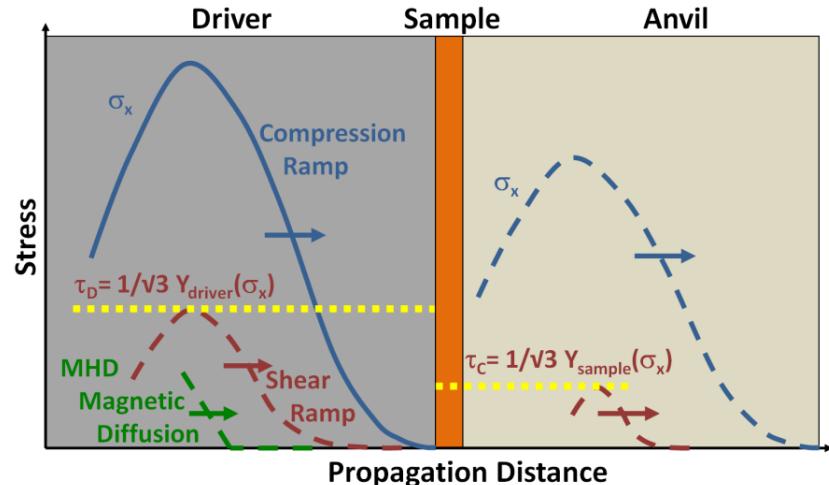
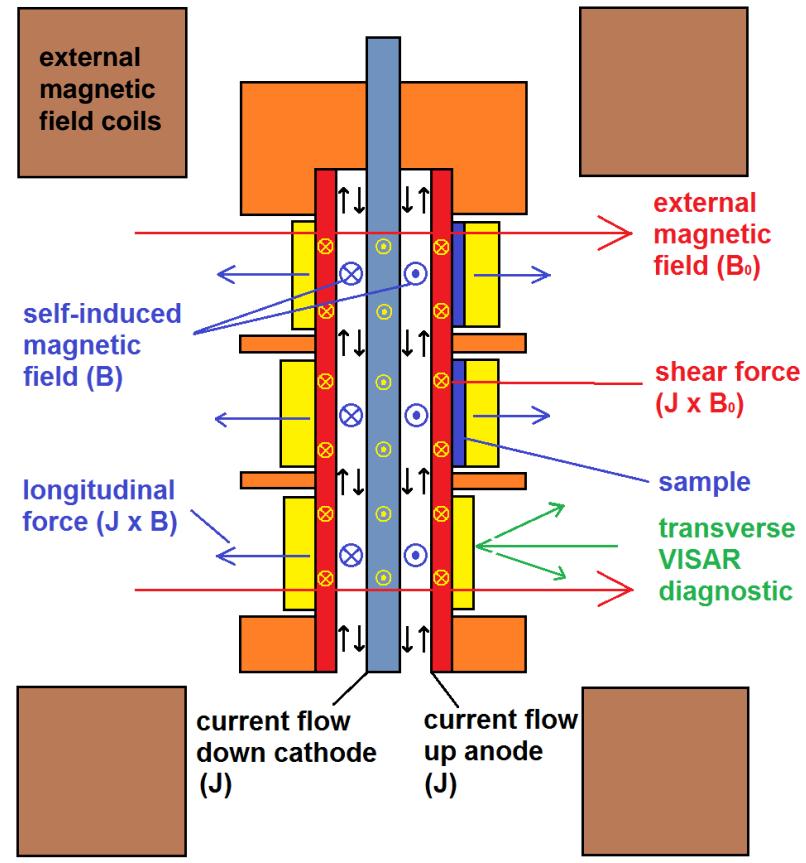


- Standard coax loads have no applied magnetic fields
- Load current generates a magnetic field in the gap between the anode and cathode
- Lorentz forces result in longitudinal stresses that drive the anode plates outward



Sandia National Laboratories

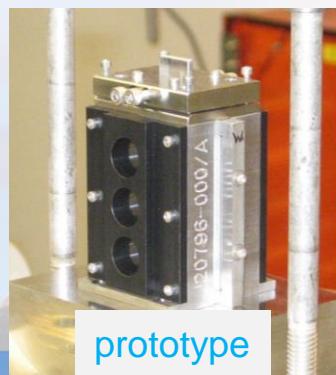
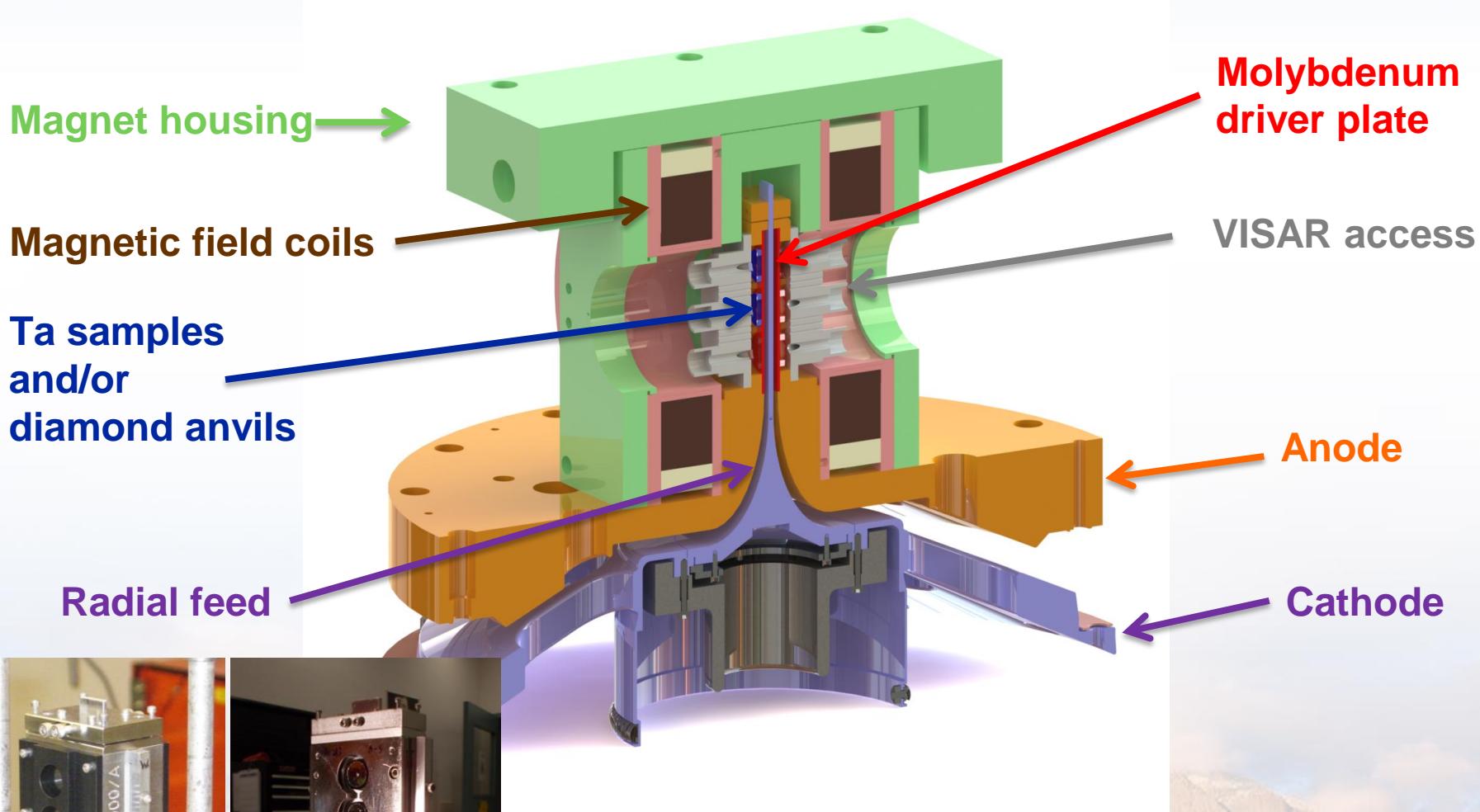
MAPS adds an applied longitudinal magnetic field to generate a shear wave



- MAPS applies an external magnetic field (B_0) that results in a shear wave
- Shear wave is truncated by sample based on material strength
- Elastic anvil material allows for coexistence of longitudinal and shear waves without coupling



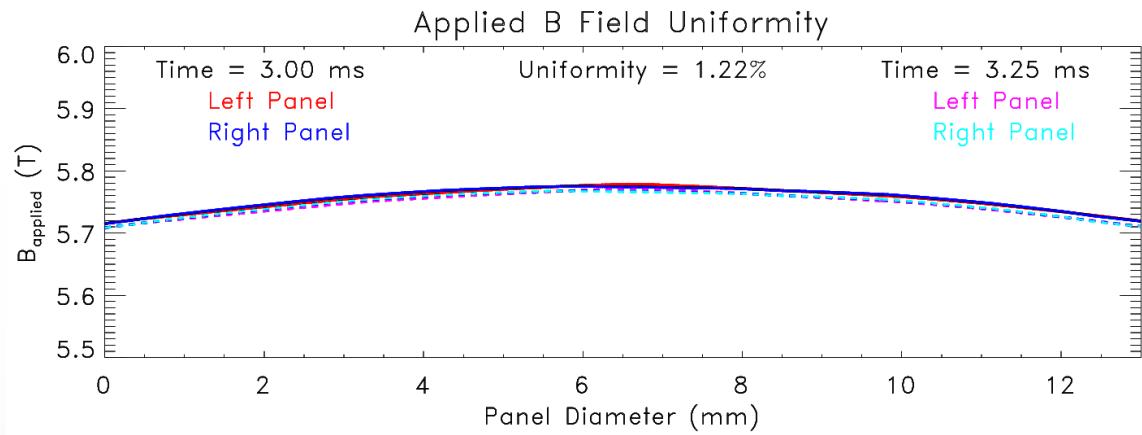
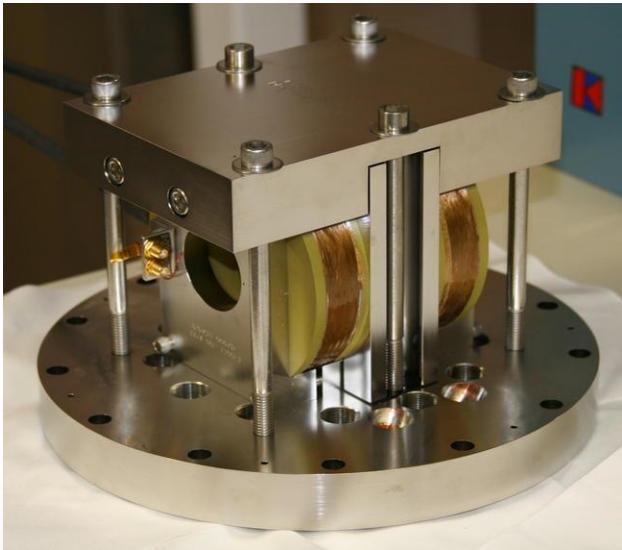
Implementation on Z requires modification of a standard coaxial load



Sandia National Laboratories



Long-pulse coils produce a uniform longitudinal magnetic field

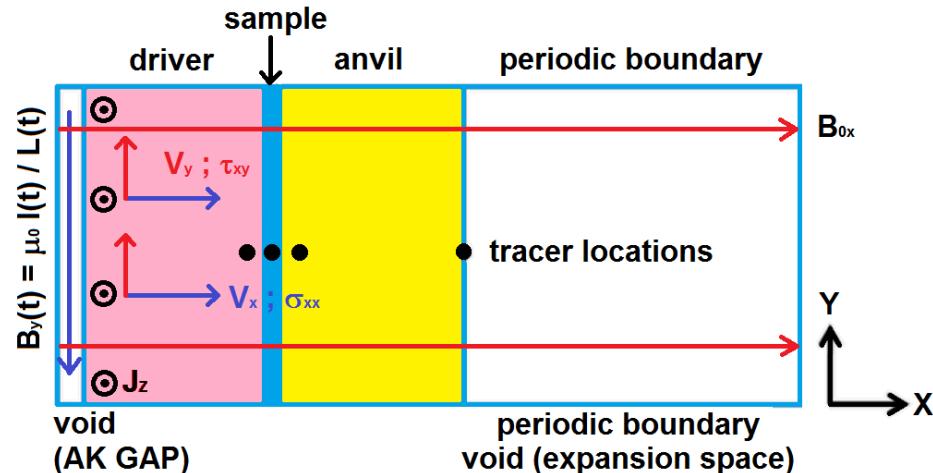


- Applied B_o coils are developed and tested at the Sandia Systems Integration Test Facility (SITF)
- Long-pulse ~4.75-ms FWHM currents drive the applied B field coils
- B field magnitude is uniform to ~1.2% across 12 mm diameter sample
- B field magnitude is uniform to <0.5% during a 250 ns time interval



ALEGRA 2D modeling is used to optimize the design of MAPS experiments

- Assume uniformity near center of sample
- 2D Cartesian Eulerian mesh
 - 5 - 10 μm cell size
- Periodic mesh in transverse or shear direction (Y)
- Uniform, static B_0 magnetic field in longitudinal direction (X)
- Current driven tangent magnetic field applied at AK gap

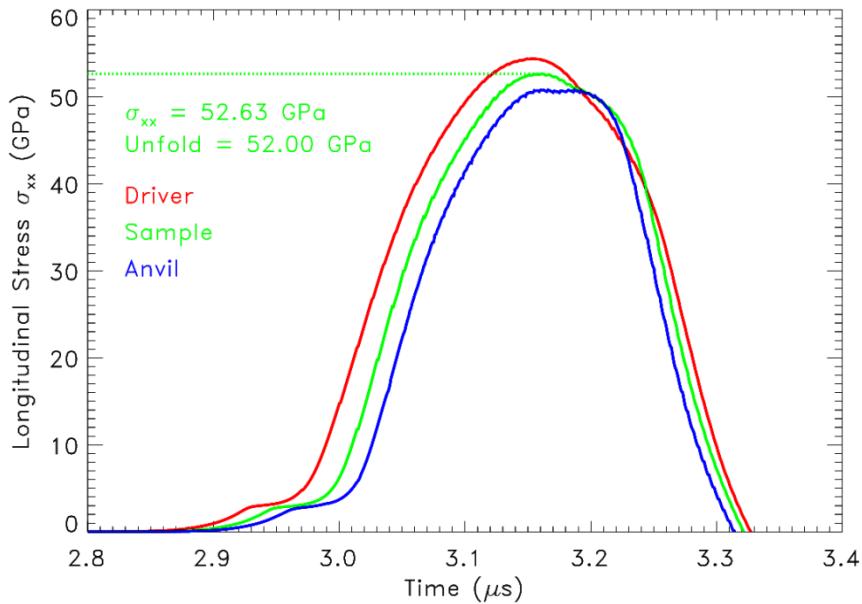


MAPS Materials and Material Model Parameters							
Panel Layer Material	Equation of State	Strength Model	Conductivity Model	Density (g/cm ³)	Longitudinal Wave Speed (km/s)	Shear Wave Speed (km/s)	Yield Strength (GPa)
Driver Molybdenum	LANL Sesame 2984	CTH Elastic-Plastic Steinberg-Guinan-Lund	Lee-More-Desjarlais (LMD)	10.22	6.45-6.45	3.47-3.48	0.9
Sample Tantalum	LANL Sesame 3720	CTH Elastic-Plastic Steinberg-Guinan-Lund	Lee-More-Desjarlais (LMD)	16.654	3.35-4.16	2.07-2.09	0.375
Anvil Diamond	LANL Sesame 7834	CTH Elastic Perfectly Plastic	Insulator	3.5126	18.328	11.659-12.0	50-90



Sandia National Laboratories

Simulated stress profiles illustrate shear wave truncation based on sample strength



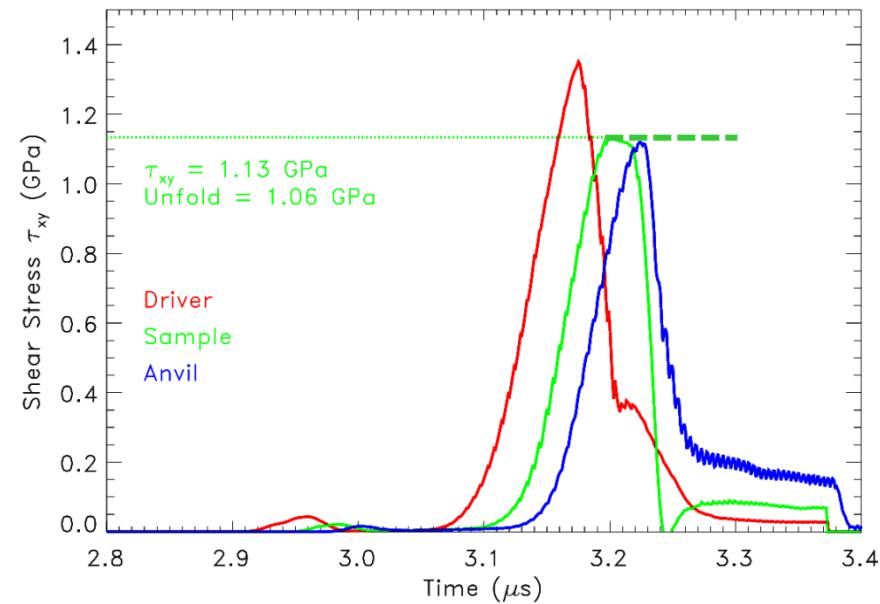
Simulated Longitudinal Stress

$$\sigma_{xx} = \rho C_L U_{PL} = \frac{1}{2} \rho C_L V_L$$

$$\sigma_{xx} = 52.00 \text{ GPa}$$

$$Y = \sqrt{3} \tau_{xy} = 1.83 \text{ GPa}$$
$$Y_{SGL} = 1.93 \text{ GPa}$$

Self-consistent



Simulated Shear Stress

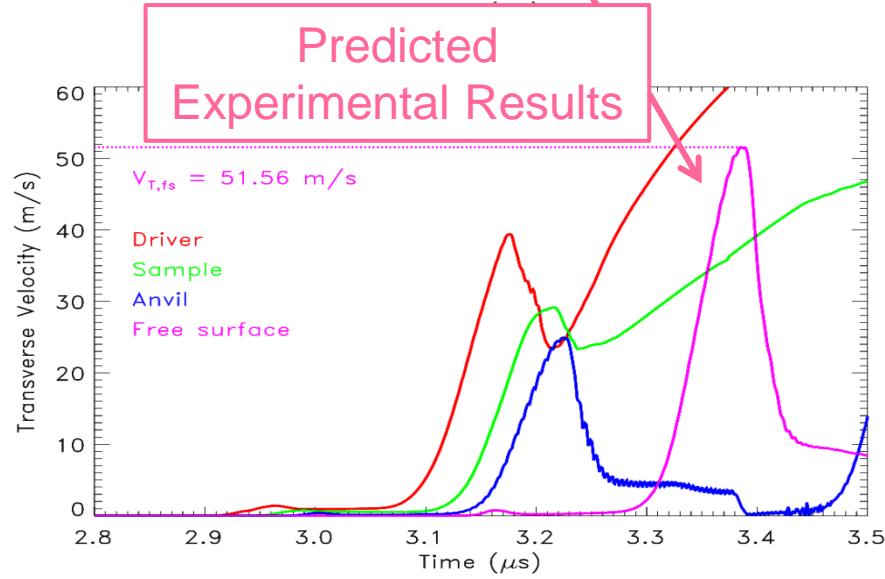
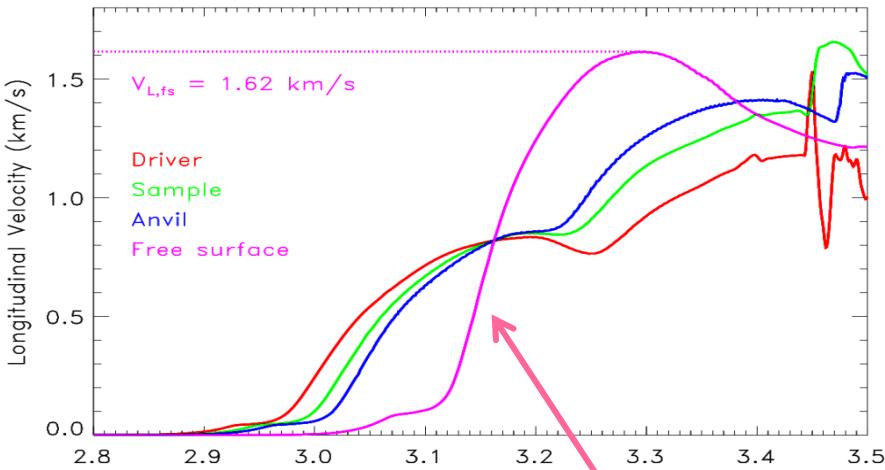
$$\tau_{xy} = \rho C_S U_{PS} = \frac{1}{2} \rho C_S V_T$$

$$\tau_{xy} = 1.06 \text{ GPa}$$



Sandia National Laboratories

Simulations predict experimental profiles and provide in-situ response



Simulated Longitudinal Stress

$$\sigma_{xx} = \rho C_L U_{PL} = \frac{1}{2} \rho C_L V_L$$

$$\sigma_{xx} = \frac{1}{2} (3.5126 \text{ g/cm}^3)(18.328 \text{ km/s})(1.62 \text{ km/s})$$

$$\sigma_{xx} = 52.1 \text{ GPa}$$

Simulated Shear Stress

$$\tau_{xy} = \rho C_S U_{PS} = \frac{1}{2} \rho C_S V_T$$

$$\tau_{xy} = \frac{1}{2} (3.5126 \text{ g/cm}^3)(11.659 \text{ km/s})(0.052 \text{ km/s})$$

$$\tau_{xy} = 1.06 \text{ GPa}$$

$$Y = \sqrt{3} \tau_{xy} = 1.83 \text{ GPa}$$
$$Y_{SGL} = 1.93 \text{ GPa}$$



Sandia National Laboratories



MAPS experiments on Z will provide a new approach to direct strength measurement

- Direct strength measurement utilizes shear wave truncation to measure dynamic strength
- Proven technique at lower pressures
- Hardware design suitable for use on Z is complete
- Applied B on Z capability will produce uniform external field to generate a stable shear wave and allow multiple samples per shot
- First experiments to be fielded soon



Sandia National Laboratories